



ALLERGEN DECLARATION

Fragrance ingredients restricted as potential allergens in Annex III of the European Cosmetic Regulation (EC) 1223/2009 and its amendments and in Schedule 34 of the Product Safety and Metrology etc. (Amendment etc.) (EU Exit) Regulations 2019 Statutory Instrument.

ESKIMOS KISS FRAGRANCE

Ingredient Name	CAS	Concentration (%)
ALPHA-ISOMETHYL IONONE	127-51-5	n.d.
AMYL CINNAMAL	122-40-7	n.d.
AMYLCINNAMYL ALCOHOL	101-85-9	n.d.
ANISE ALCOHOL	105-13-5	n.d.
BENZYL ALCOHOL	100-51-6	n.d.
BENZYL BENZOATE	120-51-4	n.d.
BENZYL CINNAMATE	103-41-3	n.d.
BENZYL SALICYLATE	118-58-1	n.d.
BUTYLPHENYL METHYLPROPIONAL	80-54-6	n.d.
CINNAMAL	104-55-2	n.d.
CINNAMYL ALCOHOL	104-54-1	n.d.
CITRAL	5392-40-5	0.225%
CITRONELLOL	106-22-9, 1117-61-9, 26489-01-0, 6812- 78-8, 141-25-3, 7540-51-4	n.d.
COUMARIN	91-64-5	n.d.
EUGENOL	97-53-0	n.d.
EVERNIA FURFURACEA EXTRACT	90028-67-4, 68648- 41-9, 68917-40-8	n.d.
EVERNIA PRUNASTRI EXTRACT	90028-68-5, 68917- 10-2, 9000-50-4	n.d.
FARNESOL	4602-84-0	n.d.
GERANIOL	106-24-1	0.010%
HEXYL CINNAMAL	101-86-0	n.d.
HYDROXYCITRONELLAL	107-75-5	n.d.
HYDROXYISOHEXYL 3-CYCLOHEXENE CARBOXALDEHYDE	31906-04-4, 51414- 25-6	n.d.
ISOEUGENOL	97-54-1, 5932-68-3, 5912-86-7	n.d.
LIMONENE	5989-27-5	5.461%
LINALOOL	78-70-6, 126-91-0	5.719%
METHYL 2-OCTYNOATE	111-12-6	n.d.

(n.d. = not detectable. Detection limit is 10ppm)

This declaration is a result of a calculated analysis of the formulation. These calculated concentrations do not replace chromatographic quantification on individual batches. Please note that the information contained herein is provided in good faith and is, to the best of our current knowledge, true and accurate at the time it is given, and may be subject to change. We are not liable for any damages that may result from the misuse of this data. It is the responsibility of the person(s) placing the finished product on the market to perform their own evaluation including with respect to finished product applications. Any Customer product, marketing or other claims are the Customer's ultimate responsibility.